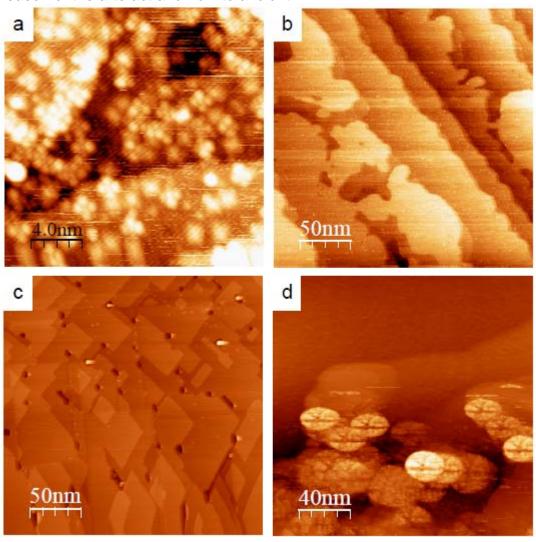
Übungen zur Oberflächenphysik

Blatt 5 - 30.04.2013

1) **STM**

- a) Calculate by how much the tunnel current changes when decreasing the tip-sample distance by 0.2 nm (a typical mono-atomic step height). Assume a work function of 4 eV which is typical for a metal.
- b) Name the two different STM operation modes that are commonly used. For each mode, indicate which quantity corresponds to the recorded signal and briefly discuss the advantages and disadvantages.
- c) The following STM images all have an artefact. For each image, briefly discuss the reason of the artefact and how to avoid it.

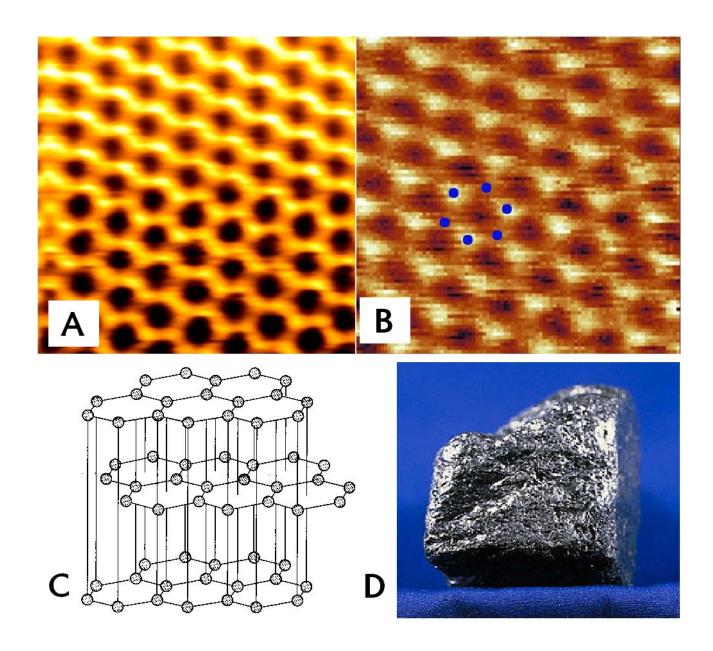


2) **AFM**

a) In case of a Lennard-Jones potential, sketch the force acting on the tip.

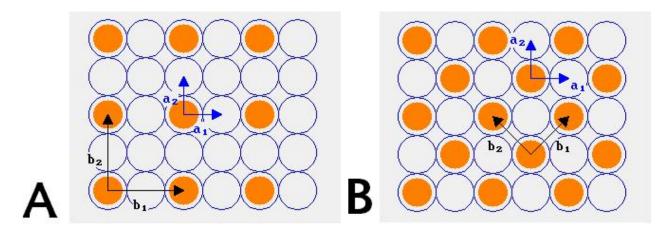
$$V = 4\varepsilon \left(\left(\frac{\sigma}{r} \right)^{12} - \left(\frac{\sigma}{r} \right)^{6} \right)$$

- b) In which range are the contact, tapping and non-contact AFM used? Where do you use a stiff respectively a soft cantilever?
- c) In the following figure there is an AFM image (A), an STM image (B), an atomic structure (C) and a picture (D) of the same substance. Answer the questions:
 - What is the substance?
 - What is the main difference between the AFM and the STM images?
 - What causes this difference?

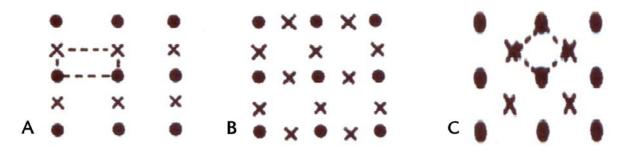


3) LEED – a 2nd attempt

a) Draw a LEED pattern of the following structures. White circles are the substrate, orange circles are the adsorbate (reconstruction).



b) Draw structures that would cause the following LEED patterns.



- c) Write the Wood's for all five presented structures and Matrix notation for the first two.
- d) In those simple drawings signal from the substrate is shown by dots and the signal from the reconstruction is show by crosses. How in a real LEED image can one distinguish them?